

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of Berry et al.

Group Art Unit: 2814

Serial No.: 09/505,695

Examiner: Le, Thao X.

Confirmation No.: 6935

Filed: February 17, 2000

For: Method of Photoresist Ash Residue  
Removal

Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

PETITION FOR EXTENSION OF TIME

Sir:

The following one-month extension of time is requested to November 11, 2003;  
the extension fee is:

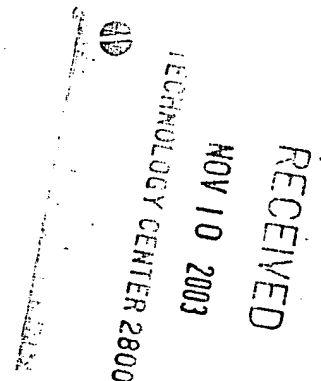
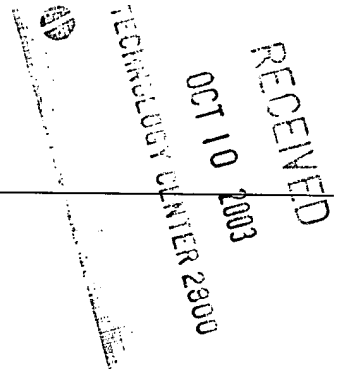
☐ \$55.00    ☒ \$110.00

- ☒ An extension fee in the amount of \$110.00 is enclosed.
- ☐ The shortened statutory period has been reset by an Advisory Action dated
- ☐ Charge \$        to Deposit Account No. 05-0460.
- ☒ The Commissioner is hereby authorized to charge any additional appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 05-0460. This paper is submitted in duplicate.

11/06/2003 CNGUYEN 00000089 09505695

01 FC:1251

110.00 OP




Dated: 11/4/03

**EDELL, SHAPIRO & FINNAN, LLC**  
**CUSTOMER NO. 27896**  
1901 Research Boulevard, Suite 400  
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(301) 424-3640

Respectfully submitted by  
**EDELL, SHAPIRO & FINNAN, LLC**

By:

  
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Martin Abramson  
Reg. No. 25,787